Backswitch poling in lithium niobate for high-fidelity domain patterning and efficient blue light generation

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In nonlinear optics applications employing quasiphase matching, short-pitch domain gratings are generally required for the efficient generation of visible and ultraviolet light. Here we introduce an improved electric-field poling technique, which incorporates spontaneous backswitching and leads to uniform short-pitch domain structures. The total volume of backswitched material, and hence the duty cycle of the backswitched domain grating, can be accurately controlled. First-order single-pass continuous-wave second harmonic generation of 60 mW at 460 nm is achieved at 6.1%/W efficiency in 0.5-mm-thick 4-μm-period backswitch-poled lithium niobate. © 1999 American Institute of Physics. [S0003-6951(99)03638-4]

Ferroelectric domain engineering is important for quasiphase matched (QPM) nonlinear optics. For QPM interactions involving visible and ultraviolet (UV) wavelengths, the dispersion characteristics of common nonlinear crystals require short-period domain gratings. To date, electric-field-poled LiTaO₃, LiNbO₃, and KTP have been reported for quire short-period domain gratings. To date, electric-field-dispersion characteristics of common nonlinear crystals are formed throughout 76-mm-diam 0.5-mm-thick LiNbO₃ uniform domain structures, having controlled duty cycle, can be continuously formed by an improved electric-field poling technique, which incorporates spontaneous backswitching and leads to uniform short-pitch domain structures. The total volume of backswitched material, and hence the duty cycle of the backswitched domain grating, can be accurately controlled. First-order single-pass continuous-wave second harmonic generation of 60 mW at 460 nm is achieved at 6.1%/W efficiency in 0.5-mm-thick 4-μm-period backswitch-poled lithium niobate. © 1999 American Institute of Physics. [S0003-6951(99)03638-4]

In the process we will refer to here as “conventional” poling, periodic bulk domain structures are produced in standard optical-grade single-domain 0.5-mm-thick LiNbO₃ wafers of congruent composition. The substrates are photolithographically patterned with periodic metal electrodes deposited on the z⁺ surface. The patterned surface is overcoated with a thin insulating layer (photoresist or spin-on glass) to inhibit domain growth between the electrodes. A high-voltage pulse, producing the optimum field of 20.75 kV/mm (Ref. 12) for which domain wall velocity is most sensitive to the average field in the crystal, is applied to the structure through a fixture containing a liquid electrolyte (typically lithium chloride). The current in the external circuit indicates the domain evolution during poling; both the voltage and current are monitored during the poling process. The charge delivered to the sample, during the poling pulse, is proportional to the volume of reversed domains and thus determines the average domain duty cycle. In conventional poling, immediately following the desired domain growth, the applied voltage is maintained at 19.5 kV/mm for 10 ms and then ramped to zero over a duration of 60 ms. This stabilization stage serves to prevent the spontaneous rever- sion of the switched domains back to the original orientation (“backswitching” or “flip back”). The polar surfaces and cross sections are etched after poling in hydrofluoric acid and the domain patterns are imaged using an optical microscope.

Domain evolution in both uniform-electrode and patterned-electrode ferroelectrics is driven by the total electric field. The total electric field is comprised of the sum of an applied external field, a depolarization field due to the unscreened portion of the polarization charge, and an internal field that has been attributed to nonstoichiometric point defects, a surface dielectric gap, and bulk charges. The depolarization field is screened in part by fast redistribution of charges at the electrodes accompanying the current in the external circuit (external screening). Nevertheless, even with complete external screening, the internal field remains. The presence of the internal field results in axial anisotropy of the coercive field, resulting in spontaneous backswitching upon abrupt removal of the external field. Due to the low electrical conductivity of the material, the redistribution of bulk charges, with a time constant on the order of days or weeks, can generally be neglected as a screening mechanism.
Screening of the internal field appears to result primarily from the reorientation of dipolar defects in the bulk material with a time constant typically on the order of milliseconds.\textsuperscript{12,16} The stabilization stage serves to allow adequate screening of the internal field to prevent backswitching.

During switching, the sign of the depolarization field changes, which, if the depolarization field is incompletely screened, results in lowering the total electric field and thereby slowing domain nucleation and growth. Conventional patterned-domain poling takes advantage of this effect by use of an insulating layer to prevent complete external screening as the domains propagate beyond the edges of the electrodes, and thus to stop domain growth at the desired duty cycle.

The substrate preparation and beginning stages of backswitch poling are similar to the conventional method, however the stabilization stage of the voltage wave form is now preceded by an additional stage in which the applied voltage is rapidly lowered [Fig. 1(a) insert].\textsuperscript{17–19} During this “low voltage” stage, spontaneous backswitching occurs, indicated by negative switching current, due to the internal field [Fig. 1(b)]. The decaying voltage measured across the sample [Fig. 1(a)] reflects the screening of the internal field. Termination of backswitching and stabilization of the domains are accomplished by applying an external voltage larger than the instantaneous value of the decaying voltage [Fig. 1(a)].

The rapid removal of the external voltage leads to domain nucleation under the edges of electrodes, similar to that of conventional forward switching, but at higher spatial density. In addition, sideways motion of the residual domain walls occurs during backswitching. These processes lead to high-fidelity short-period domain structures. Figures 2(a) and 2(b) show uniform 4-\(\mu\text{m}\)-period domains in 0.5-mm-thick periodically poled LiNbO\(_3\).
were forward poled until the duty cycles of the domains reached approximately 50%; they then suffered electrical breakdown near the o-rings of the poling fixture. The breakdown occurred before the stabilization voltage was applied and the domains were therefore allowed to spontaneously backswitch. Figure 3(a) is a \( z^+ \) surface image taken from one of these wafers, which demonstrates the possibility of spatial frequency doubling of 10-\( \mu \)m-period domains. In this case, the domain depth is typically 50–100 \( \mu \)m for 1 \( \mu \)m domain widths.

Backswitch poling in LiNbO\(_3\) enables higher fidelity and shorter period domain patterning of thick substrates than can be achieved with conventional poling. Future work will include the extension of this technique to other ferroelectric materials. Further studies to elucidate the mechanism of the spatial frequency multiplication, and control it through variation of the duty cycle of the electrodes and duration of back-switching, may enable waveguide devices having sub-\( \mu \)m domain structures.

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